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U.S. Patent and Trademark Office: U.S. DEPARTMENT OF COMMERCE

| | Applicant | Initiated In | terview | Reque | st Fo | rm | | | |
|--|--|--------------------------|-------------------|----------------|---------------|---------------|-------------------------|------------|--|
| Application No.: 10/563 | 3,268 | First Named Applie | ant: Hid | eo Nagai | | | | | |
| Examiner: Pham, Long | | Art Unit: 2814 | Stat | us of Appl | lication: | 2nd OA | | _ | |
| Tentative Participants: (1) Long Pham | | (2) <u>Joe Pr</u> | ice | | | | | | |
| (3) | | (4) | | | | | | | |
| Proposed Date of Intervi | Proposed Ti | me: | 2:00 F | M EST | (AM/PM) | | | | |
| Type of Interview Reque (1) [×] Telephonic | sted: (2) [] Perso | onal (3) [|] Video Cor | ıference | | | | | |
| Exhibit To Be Shown or If yes, provide brief desc | | [] YES | ٤× |] NO | | | | | |
| 0 | | Issues To B | e Discusso | ed | | | | _ | |
| Issues (Rej., Obj., etc.) | Claims / Fig. #s | Prior Art | D | Discussed | | greed | Not Agree | Not Agreed | |
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| (3) | | | [| 1 | ſ | 1 | [] | | |
| (4) | | | [| 1 | ι | 1 | [] | | |
| [] Continuation Sheet A | Attached | | | | | | | | |
| Brief Description of Argu See attached document fo | | | | | | | | | |
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| An interview was conducted the MOTE: This form should (see MPEP § 713.01). This application will not interview. Therefore, application will not interview. | l be completed b be delayed fron | by applicant and s | ubmitted to | failure to | submit : | a written | record of this | | |
| as soon as possible. | | i to inc a statemen | it of the subs | tance of t | mis meer | view (57 | CFK 1.135(b)) | | |
| Applicant Applicant's | Signature | Examiner / SPE Signature | | | | | | | |
| Joseph | | | | | | | | | |
| Typed/Printed Name of | | resentative | | | | | | | |
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| his collection of information is requ | mber, if applicable ired by 37 CFR 1.133. | | ired to obtain or | retain a benel | fit by the pu | blic which is | to file (and by the USI | PTC | |

process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.11 and 1.14. This collection is estin sted to take 21 minutes to complete, including gathering, preparing, and submitting the completed application form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, VA 22313-1450. DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Patent Examiner: Pham, Long

Hideo Nagai

Group Art Unit: 2814

Application No.: 10/563,268

Confirmation No.: 6407

Filed: January 4, 2006

For: SEMICONDUCTOR LIGHT

May 29, 2009

EMITTING DEVICE, METHOD OF MANUFACTURING THE SAME AND LIGHTING APPARATUS AND

Costa Mesa, California 92626

DISPLAY APPARATUS USING THE

SAME

REQUEST FOR TELEPHONE INTERVIEW

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Applicant requests a telephone interview with regards to the allowed dependent Claims 12, 13, 34 and 35. Please see the following:

IN THE CLAIMS:

(12) 1. (Currently Amended) A semiconductor light emitting device having a luminous layer, comprising:

a light transmission layer disposed over a main surface of the luminous layer, and having depressions on a surface facing away from the luminous layer; and

a transmission membrane disposed on the light transmission layer so as to follow contours of the depressions, wherein

light from the luminous layer is irradiated so as to pass through the light transmission layer and the transmission membrane, wherein the transmission membrane contains a luminous substance that is excitable by the light from the luminous layer, the luminous layer is sandwiched between a plurality of layers and is disposed over the light transmission layer,

wherein the light transmission layer is made of a material having a refractive index that is substantially equal to a refractive index of the luminous layer and the material for the light transmission layer is selected from a group of GaN, SiC, and A1N.

- (13) 1. (Currently Amended) A semiconductor light emitting device having a luminous layer, comprising:
- a light transmission layer disposed over a main surface of the luminous layer, and having depressions on a surface facing away from the luminous layer; and

a transmission membrane disposed on the light transmission layer so as to follow contours of the depressions, wherein

light from the luminous layer is irradiated so as to pass through the light transmission layer and the transmission membrane, wherein the transmission membrane contains

a luminous substance that is excitable by the light from the luminous layer, the luminous layer is sandwiched between a plurality of layers and is disposed over the light transmission layer, wherein a reflective film is disposed on a surface of the luminous layer facing away from the light transmission layer.

(34). 31. (Currently Amended) A semiconductor light emitting device having a luminous layer, comprising:

a light transmission layer disposed over a main surface of the luminous layer, and having depressions on a surface facing away from the luminous layer; and

a transmission membrane disposed on the light transmission layer so as to follow contours of the depressions, wherein

light from the luminous layer is irradiated so as to pass through the light transmission layer and the transmission membrane, wherein the light transmission layer is formed from at least a light transmission substrate; and

the luminous layer is sandwiched between a plurality of layers and is disposed over the light transmission substrate layer, wherein light transmission layer is made of a material selected from a group of GaN, SiC, and A1N having a refractive index that is substantially equal to a refractive index of the luminous layer.

(35). 31. (Currently Amended) A semiconductor light emitting device having a luminous layer, comprising:

a light transmission layer disposed over a main surface of the luminous layer, and having depressions on a surface facing away from the luminous layer; and

a transmission membrane disposed on the light transmission layer so as to follow contours of the depressions, wherein

light from the luminous layer is irradiated so as to pass through the light transmission layer and the transmission membrane, wherein the light transmission layer is formed from at least a light transmission substrate, and

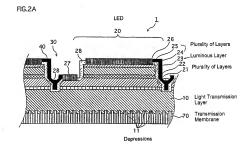
the luminous layer is sandwiched between a plurality of layers and is disposed over the light transmission substrate layer, wherein a refractive index that is substantially equal to a refractive index of the luminous layer, wherein a reflective film is disposed on a surface of the luminous layer facing away from the light transmission layer.

REMARKS

The Office Action indicated that Claims 12, 13, 34 and 35 would be allowed if rewritten in independent form.

In reviewing the claims, we noted a potential issue referring to both a light transmission layer and substrate. Applicant, accordingly, requests the comments of the Examiner on our proposed amendments to clarify the issue.

In this regard, the light transmission layer, which is over the main surface of the luminous layer, has a series of depressions 11 with a transmission member disposed on the light transmission layer, so as to follow the contours of the depressions. This is disclosed as follows:



Our Specification, Page 3, Line 26 to page 4, Line 5 states as follows:

In order to achieve the above object, a semiconductor light emitting device having a <u>luminous layer</u> according to the present invention comprises a <u>light transmission layer</u> disposed over a main surface of the luminous layer, and having <u>depressions</u> on a surface facing away from the luminous layer, and <u>a transmission membrane disposed on the light transmission layer</u> so as to follow contours of the depressions, and light from the luminous layer is irradiated so as to pass through the light transmission layer and the transmission membrane.

Patent 92478-9000

Our original claims defined a light transmission layer with depressions, for example in

Claim 1.

However, dependent Claim 9 defined the light transmission layer as "formed from at least

a light transmission substrate."

Applicant intends to consistently use the words "light transmission layer" to avoid any

confusion and to give a proper scope to the claims and requests the Examiner's advice on the

currently proposed amended claims without the term --substrate--.

Very truly yours,

SNELL & WILMER L.L.P.

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